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# Chemical Solution Deposition Of Semiconductor Films

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## Chemical Solution Deposition of Semiconductor Films By ...

Chemical Deposition Chemical Deposition is the precipitation of a metal salt dissolved in a chemical solution. The metal salt is then combined with another metal while in the solution. One common use of chemical deposition in metal finishing is in the

semiconductor industry.

Discussing specific depositions of a wide range of semiconductors and properties of the resulting films, Chemical Solution Deposition of Semiconductor Films examines the processes involved and explains the effect of various process parameters on final film and film deposition outcomes through the use of detailed examples. Supplying experimental res

The chemical solution deposition (CSD) process is a wet-chemical process that has been used to design a wide variety of amorphous and crystalline oxide thin films. Compared to vapour and plasma processes, the thermodynamic driving force for the

formation and crystallization of a solid phase from liquid-based solutions is much smaller.

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The bath solution contained cadmium acetate dehydrate [Cd(CH<sub>3</sub>COO)<sub>2</sub>·2H<sub>2</sub>O], so-dium selenosulphate [Na<sub>2</sub>SeSO<sub>3</sub>] and thiourea [CS(NH<sub>2</sub>)<sub>2</sub>] were used as the sources of Cd<sup>2+</sup>, Se<sup>2+</sup> and S<sup>2+</sup>, respectively. Tartaric acid (C<sub>4</sub>H<sub>6</sub>O<sub>6</sub>) was used as a complexing agent. The pH of the solution was adjusted to 12 by drop-wise addition of ammonia.

### **Hodes, G. (2002) Chemical Solution**

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### **REFERENCE 1. Vacuum Technology, Thin Films, and Sputtering ...**

Chemical Solution Deposition of Semiconductor Films By Gary Hodes (Weizmann Institute). Marcel Dekker, Inc.: New York and Basel. 2003. xii + 376 pp. \$150.00. ISBN 0-8247-0851-2. Mark T. Spitler

### **Chemical Solution Deposition of Semiconductor Films By ...**

It was not commonly used in semiconductor processing for many years, but has seen a resurgence with more widespread use of chemical-mechanical polishing techniques. Chemical solution deposition (CSD) or chemical bath deposition (CBD) uses a liquid precursor, usually a solution of organometallic powders dissolved in an organic solvent. This is a relatively inexpensive, simple thin-film process that produces stoichiometrically accurate crystalline phases.

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## **Thin film - Wikipedia**

Mechanistic Study of Chemical Deposition of ZnS Thin Films from Aqueous Solutions Containing Zinc Acetate and Thioacetamide by Comparison with Homogeneous Precipitation. The Journal of Physical Chemistry B 2003 , 107 (1) , 387-397.

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## **Chemical Solution Deposition Of Semiconductor Films (Food ...**

To deposit layers of silicon nitride or silicon oxynitride one has to use gases which contain all necessary components. The gases are decomposed via thermal energy. That's the principle of the chemical vapor phase deposition: CVD. The wafer surface doesn't react with the gases but serves as bottom layer.

## **Chemical vapor deposition - Deposition - Semiconductor ...**

? Thin film transistors with PbS as semiconductor deposited by chemical bath deposition. ? Photolithography-based thin film transistors with PbS films at low temperatures. ? Electron mobility for annealed PbS devices of  $\sim 0.14 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ . ? Highest mobility reported in thin film transistors with PbS as the semiconductor.

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